

UNITED STATES DEPARTMENT OF COMMERCE

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR			ATTORNEY DOCKET NO.
08/932.767	12/17/97	YOUGYAHA		1.2	MED-19654
- MARKET 2 40 5 20			٦		EXAMINER
HAYES SCHOMAN HEMMESSEN SHODSMAN MASSNOSSO ,				Minter to	Ţ:
& HAGE 175 CANAL S	nesen			ART UNIT	PAPER NUMBER
MANCHESTER MH 03101				2814	
				DATE MAILED:	0.6.750.700

Please find below and/or attached an Office communication concerning this application or pr ceeding.

Commissioner of Patents and Trademarks

08/30/00

PTO-90C (Rev. 2/95) 1- File Copy

Office Action Summary

Application No. 08/992,767 Applicant(s)

Yokoyama

Examiner

Douglas Wille

Group Art Unit 2814



Responsive to communication(s) filed on May 16, 2000	·
☑ This action is FINAL.	
☐ Since this application is in condition for allowance except for for in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C	
A shortened statutory period for response to this action is set to e is longer, from the mailing date of this communication. Failure to application to become abandoned. (35 U.S.C. § 133). Extensions 37 CFR 1.136(a).	respond within the period for response will cause the
Disposition of Claims	
X Claim(s) 1-10	is/are pending in the application.
Of the above, claim(s)	is/are withdrawn from consideration.
Claim(s)	is/are allowed.
X Claim(s) 1-10	is/are rejected.
☐ Claim(s)	is/are objected to.
☐ Claims	are subject to restriction or election requirement.
Application Papers See the attached Notice of Draftsperson's Patent Drawing Filed on	to by the Examiner isapproveddisapproved. der 35 U.S.C. § 119(a)-(d). the priority documents have been er) ternational Bureau (PCT Rule 17.2(a)).
Attachment(s) Notice of References Cited, PTO-892 Information Disclosure Statement(s), PTO-1449, Paper No(s) Interview Summary, PTO-413 Notice of Draftsperson's Patent Drawing Review, PTO-948 Notice of Informal Patent Application, PTO-152	s)
SEE OFFICE ACTION ON THE	F FOLLOWING PAGES

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1 The text of those and a prior Office action.
- Claims 1 4, 7 and 8 are rejected under 35 U.S.f. 103(a) as being unpatentable over Ohori et al. in view of Roberts et al. and Miller et al.
- 3. Ohori et al. show (see cover Figure and column 4, line 34 et seq.) a structure with different sized vias with both high and low aspect ratios 38 a, 38 b for contacting different portions of the device. Roberts et al. show (see cover Figure and column 2, line 37 column 7, line 12) a structure with a wide via (low aspect ratio) in an insulating layer 12 where a tapered refractory metal layer 30 is formed in the corners of the hole to improve step coverage of the metal film 40 and the upper end of the hole is funnel shaped. Miller et al. show (see cover Figure and column 5, line 22 column 6, line 30) the filling of a high aspect ratio hole (column 2, line 43) with a refractory metal plug. It would have been obvious to include a technique for filling a high aspect ratio hole along with an approach to filling a low aspect ratio hole to provide a technique for providing both size vias in a regime where the hole size is small enough to cause concern
- Claims 1 4, 7 and 8 are rejected under 35 U.S.C. 103(a) as being unpatentable over
 Ohori et al. in view of McDavid and Miller et al.

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- 5. Ohori et al. show (see cover Figure and column 4, line 34 et seq.) a structure with different sized vias 38 a, 38 b for contacting different portions of the device. McDavid shows (see cover Figure and column 2, line 19 line 61) a structure with a wide via (low aspect ratio) in an insulating layer 21 where a tapered refractory metal layer 13 is formed in the corners of the hole to improve step coverage of the metal film 10 and the upper end of the hole is funnel shaped.

 Miller et al. show (see cover Figure and column 5, line 22 column 6, line 30) the filling of a high aspect ratio hole (column 2, line 43) with a refractory metal plug. It would have been obvious to include a technique for filling a high aspect ratio hole along with an approach to filling a low aspect ratio hole to provide a technique for providing both size vias in a regime where the hole size is small enough to cause concern.
- 6. Claims 5, 6, 9 and 10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ohori et al., McDavid and Roberts et al. in view of Miller et al.
- 7. McDavid shows a refractory layer which is high in form and Roberts et al. show a refractory layer that is low in form. Since both show a useful structure it would have been obvious to use any form in-between the two.

Response to Arguments

8. Applicant's arguments with respect to claims 1 - 10 have been considered but are moot in view of the new ground(s) of rejection.

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Conclusions

9. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office

action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is

reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

10. A shortened statutory period for response to this final action is set to expire THREE

MONTHS from the date of this action. In the event a first response is filed within TWO

MONTHS of the mailing date of this final action and the advisory action is not mailed until after

the end of the THREE-MONTH shortened statutory period, then the shortened statutory period

will expire on the date the advisory action is mailed, and any extension fee pursuant to 37

CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event will the

statutory period for response expire later than SIX MONTHS from the date of this final action.

11. Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Douglas A. Wille whose telephone number is (703) 308-4949.

12. Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the Group receptionist whose number is (703) 308-0956,

Olik Chaudhuri Supervisory Patent Examiner

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June 21, 2000